Call for papers

An official publication of The Minerals, Metals & Materials Society



Publication Date: *December 2018*Manuscript Deadline: *July 1, 2018*

The Nanomaterials Committee is seeking papers on the topic of Application of Atomic Layer Deposition for Functional Nanomaterials

Atomic layer deposition (ALD), an advanced thin film coating method used to fabricate ultrathin, highly uniform and conformal material layers, is increasingly finding unique uses in generating functional nanomaterials. The theme will cover the recent advances in ALD for fabricating functional nanomaterials having novel material properties and technological applications.

Original research papers should be 3,000-6,000 words with up to 8 figures maximum; review papers should be 6,000-10,000 words with up to 15 figures maximum.

Detailed author instructions are available at:

http://www.tms.org/AuthorTools/

Guest Editor for this *JOM* topic is Chang-Yong Nam: cynam@bnl.gov

If you are interested in submitting a paper, upload your manuscript at https://www.editorialmanager.com/jomj/

Please note that all submissions will be subject to peer review. Submission does not guarantee acceptance.